



PATENT
Attorney Docket No. 14912.777

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of)
)
 Stephen E. Savas)
)
 Application No.: 09/692,255)
)
 Filed: 10/19/2000)
)
 For: Systems and Methods for Photoresist Strip)
 And Residue Treatment in Integrated)
 Circuit Manufacturing)

Group Art Unit: 1746
Examiner: Alexander Markoff

12/13
1/28/13

Mail Stop Fee Amendment
Commissioner for Patents
PO Box 1450
Alexandria, VA 22313-1450

RESPONSE TO OFFICE ACTION

Introductory Comments:

Applicants submit this Amendment in response to the Office Action mailed on March 31, 2003. Reconsideration of the above referenced application is respectfully requested in view of the following amendments and remarks.